		Applicant(s)	
	09/499,027	HOSODA ET AL.	
Notice of Allowability	Examiner	Art Unit	
	Delma R. Flores Ruiz	2828	
The MAILING DATE of this communication app	<u> </u>		
All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	) or other appropriate commun RIGHTS. This application is sul	cation will be mailed in due course. TH	IIS tiative
1. This communication is responsive to 12/2/2003.			
2. X The allowed claim(s) is/are 1 -,7,10,11,and 16-20.			
3. The drawings filed on <u>07 February 2000</u> are accepted by t			
<ul> <li>4.</li></ul>	nder 35 U.S.C. § 119(a)-(d) or	<b>(f)</b> .	
<ol> <li>Certified copies of the priority documents have</li> </ol>	e been received.		
2. Certified copies of the priority documents have	• •	<del></del>	
<ol><li>Copies of the certified copies of the priority do</li></ol>	ocuments have been received i	n this national stage application from th	те
International Bureau (PCT Rule 17.2(a)).			
<ul> <li>* Certified copies not received:</li> <li>5.  Acknowledgment is made of a claim for domestic priority ureference was included in the first sentence of the specific</li> </ul>			
(a) The translation of the foreign language provisional	· ·		
6. Acknowledgment is made of a claim for domestic priority up in the first sentence of the specification or in an Application		121 since a specific reference was inclu	uded
Applicant has THREE MONTHS FROM THE "MAILING DATE" o below. Failure to timely comply will result in ABANDONMENT of			
7. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which giv			
8. CORRECTED DRAWINGS (as "replacement sheets") must	st be submitted.		
(a) I including changes required by the Notice of Draftspers	son's Patent Drawing Review (	PTO-948) attached	
1) ☐ hereto or 2) ☐ to Paper No			
(b) ☐ including changes required by the proposed drawing of			
(c) including changes required by the attached Examiner	s Amendment / Comment or in	the Office action of Paper No	
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t			
9. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT FOR 1			
Attachment(s)			
1 Notice of References Cited (PTO-892)	5 ☐ Notice of Inform	nal Patent Application (PTO-152)	
<ul> <li>2 Notice of Draftperson's Patent Drawing Review (PTO-948)</li> <li>3 Information Disclosure Statements (PTO-1449 or PTO/SB/08)</li> <li>Paper No.</li> </ul>		nary (PTO-413), Paper No	
	<sup>3),</sup> 7□ Examiner's Am	endment/Comment	
4	8 <b>⊠</b> Examiner's Sta	tement of Reasons for Allowance	
of Biological Material	9∏ Other .	Pos	
		PAUL IP	1
	9112	PERVISORY PATENT EXAMINER	

U.S. Patent and Trademark Office

TECHNOLOGY CENTER 2800

Application/Control Number: 09/499,027

Art Unit: 2828

## **DETAILED ACTION**

## Allowable Subject Matter

The following is an examiner's statement of reasons for allowance: claim 1 has been allowed over the prior art because they fail to teach a semiconductor laser device comprising; a first and second of semiconductor laser resonators having light emitting active layers of materials different from each other, the semiconductor laser resonators being provided on the same semiconductor substrate so that the light emitting active layers lie substantially in parallel to a main surface of the semiconductor substrate, said first semiconductor laser resonator being located in a groove including a base and sidewalls, and said second semiconductor laser resonator not being located in said groove; and a high-resistance region in a sidewall of said groove which is provided between the semiconductor laser resonators, said high-resistance region having sufficient resistance to electrically isolate the first and second semiconductor laser resonator from one another.

The following is an examiner's statement of reasons for allowance: claim 16 has been allowed over the prior art because they fail to teach a semiconductor laser device comprising; a first and second of semiconductor laser resonators provided on the same substrate, an active layer of the first laser resonator being of different material than an

Application/Control Number: 09/499,027

Art Unit: 2828

resonator being provided in a groove whereas the active layer of the first laser resonator is not provided in a groove and a high-resistance region provided at least along a sidewall of said groove which the active layer of the second laser resonator is provided, the high resistance region comprising ions and/or protons implanted into the sidewall of the groove.

The following is an examiner's statement of reasons for allowance: claim 20 has been allowed over the prior art because they fail to teach a semiconductor laser device comprising; a first and second of semiconductor laser resonators having different light emitting active layers of materials different from each other, the semiconductor laser resonators being provided on the same substrate so that the light emitting active layers lie substantially in parallel to a main surface of the semiconductor substrate, an isolating groove defined between the first and second semiconductor laser resonators for electrically isolating the first and second semiconductor laser resonator from one another; each of said first and second semiconductor laser resonators being mounted on a heat sink having a concave portion defined in a surface thereof, and each of the semiconductor laser resonator being mounted in a junction-down manner in the heat sink so that in each semiconductor laser resonator a cap layer thereof is located between the heat sing and an active layer, thereof, and so that the active layer of each semiconductor laser resonator is

located between said substrate and the heat sink; and wherein at least a portion of said isolating groove extends upward from the concave portion defined in the

surface of the heat sink.

Claims 2 – 7, 10 – 11 and 17 - 19 has been found allowable due to their

dependency on claims 1, 16 and 20.

Any comments considered necessary by applicant must be submitted no later

than the payment of the issue fee and, to avoid processing delays, should preferably

accompany the issue fee. Such submissions should be clearly labeled "Comments on

Statement of Reason for Allowance".

Conclusion

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Delma R. Flores Ruiz whose telephone number is (703)

308-6238. The examiner can normally be reached on M - F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Paul Ip can be reached on (703) 308-3098. The fax phone number for the

organization where this application or proceeding is assigned is (703) 308-7722.

Paul Ip

Art Unit: 2828

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 306-

3431.

Delma R. Flores Ruiz

Examiner

Supervisor Patent Examiner Art Unit 2828 Art Unit 2828

DRFR/PI December 18, 2003